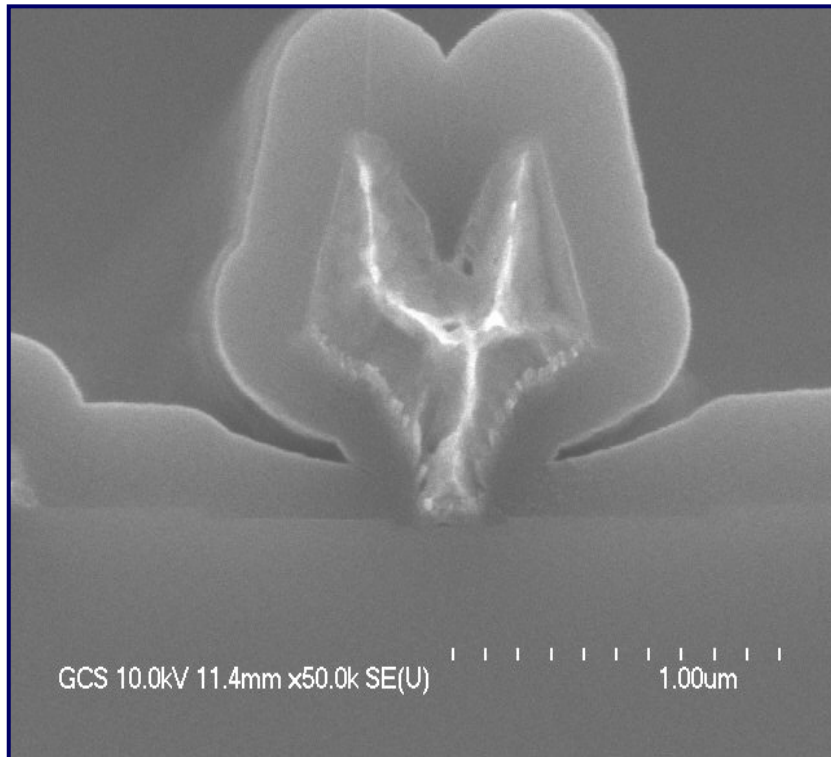


# 0.25 $\mu$ m T-Gate PHEMT Power Process



GCS' 0.25 $\mu$ m T-Gate PHEMT features:

- Low-cost optical stepper lithography process
- Extremely high  $f_{max}$  (>200GHz)
- Very high breakdown voltage (>20V)



| Device Parameters              | Typical Values |
|--------------------------------|----------------|
| $I_{dss}$ @ $V_{gs}=2V$        | 270mA/mm       |
| $I_{max}$ @ $V_{gs}=0.9V$      | 500mA/mm       |
| $V_p$ @ $I_{ds}=1mA/mm$        | -1V            |
| $g_m$ @ $V_{gs}=-0.3V$         | 330mS/mm       |
| $BV_{gd}$ @<br>$I_{gd}=1mA/mm$ | >20V           |

# RF Performance of 0.25 $\mu$ m PHEMT



## Small Signal Performance

- $f_T > 60$  GHz
- $f_{max} > 200$  GHz
- $G_{max} > 15$  dB at 40 GHz

## Large Signal Performance

| Frequency   | (GHz)   | 2   |     | 30   |      |
|-------------|---------|-----|-----|------|------|
| Vds         | (V)     | 8   | 10  | 3.5  | 6    |
| Sat. Power  | (mW/mm) | 650 | 840 | 180  | 400  |
| Assoc. Gain | (dB)    | 15  | 17  | 9.0  | 9.4  |
| P.A.E.      | (%)     | 60  | 50  | 56.0 | 41.4 |